# Linear collider: Electron and positron source Potential R&D items

G. Dugan 3/11/02

# Electron Source: Potential R&D Items

- Polarized dc electron gun cathode development
- Polarized rf electron gun
- Flat beam electron gun
- Polarized electron gun laser system development

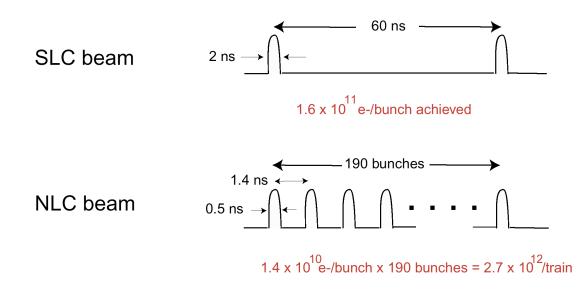
### Electron sources: R&D items

Polarized electron gun cathode development-from LC'02 presentation of T.Maruyama (SLAC)

#### SLC had 80% polarization. Why more research?

SLC photocathode cannot produce NLC beam with 80% polarization due to the surface charge limit.

Polarization will be  $60 \sim 65\%$ .

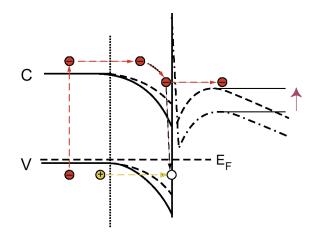


#### Goals

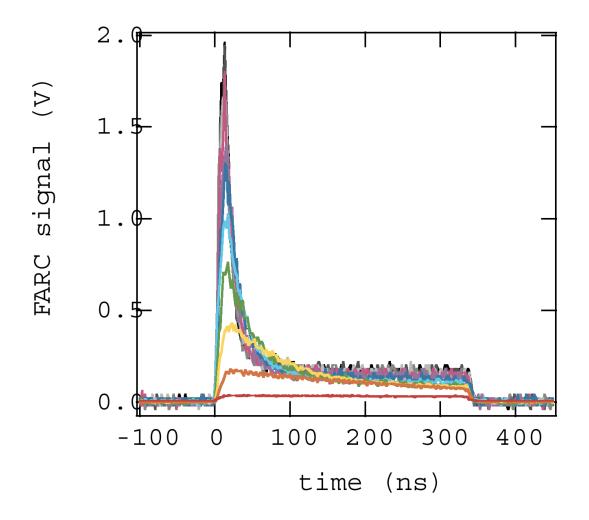
- Produce NLC beam with 80% polarization
- Higher polarization

#### Surface Charge Limit

Charge output is not proportional to light intensity

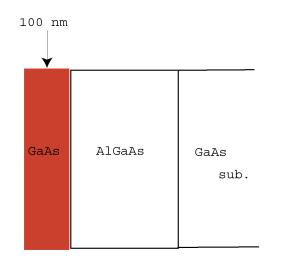


- Photon absorption excites electrons to conduction band
- Electrons can be trapped near the surface
- Electrostatic potential from trapped electrons raises affinity
- Increased affinity decreases emission probability
- Affinity recovers after electron recombination
- Increasing photon flux counterproductive at extremes



#### **Charge Limit vs. Doping Concentration**

#### Samples: thin unstrained GaAs grown by Quantum Epitaxial Devices



**Doping concentration:** 

 $5 \cdot 10^{18}$ ,  $1 \cdot 10^{19}$ ,  $2 \cdot 10^{19}$ ,  $5 \cdot 10^{19}$  cm<sup>-3</sup>

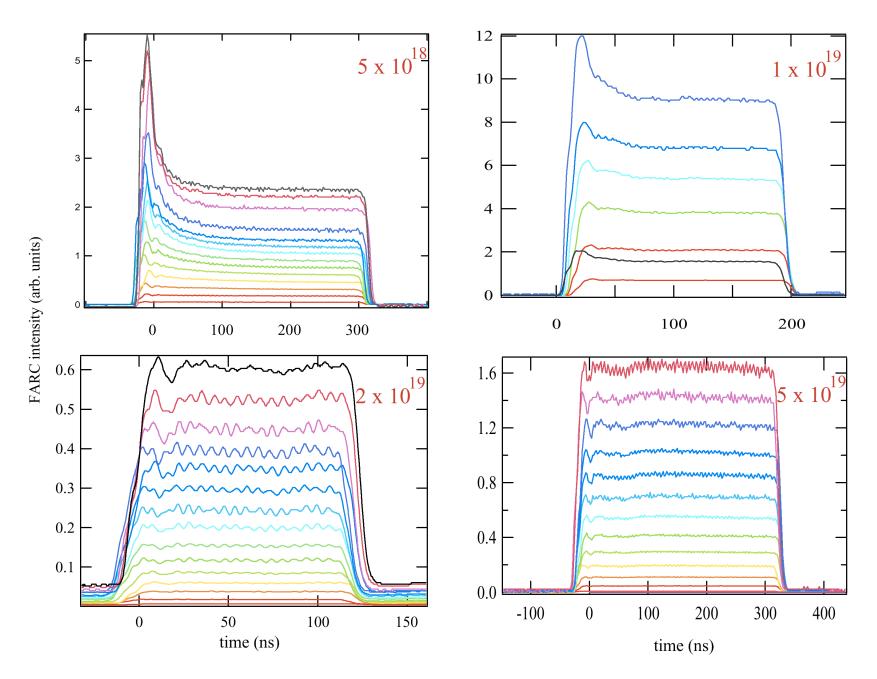
Measure charge output

Measure charge restoration time

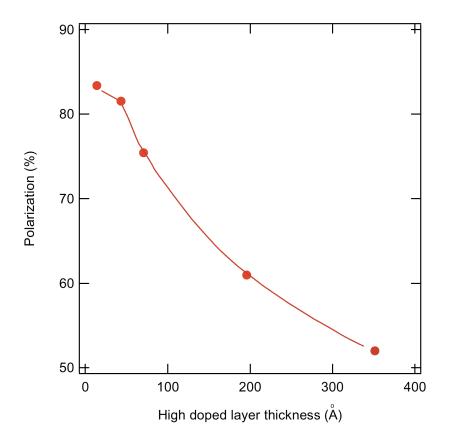
Develop photovoltage model

Published in Physics Letters A282, 309 (2001)

#### Faraday Cup Signal



#### Polarization vs High Doped Layer Thickness

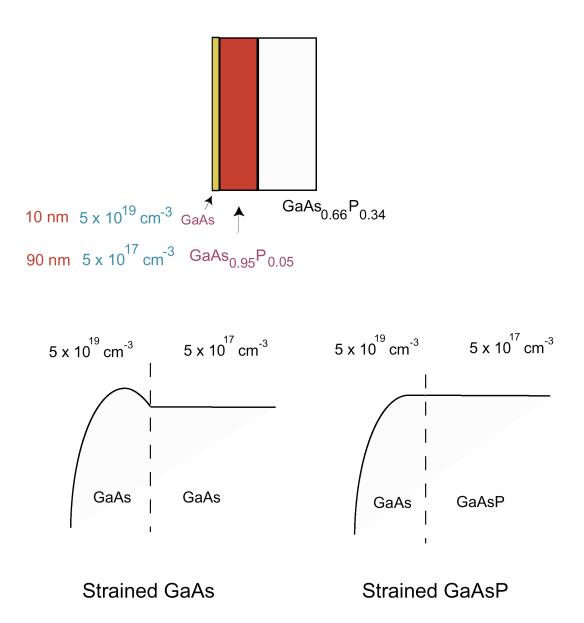


#### High doping depolarizes spin.

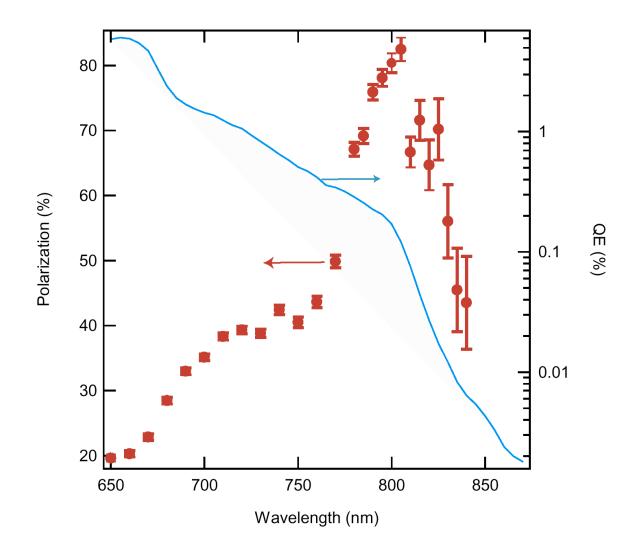
Possible to reach ~80 % polarization with 50 ~ 75  $\stackrel{\circ}{A}$  of high surface doping.

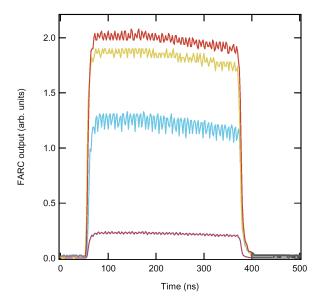
High-Gradient-Doped Strained GaAsP

Grown by Bandwidth Semiconductor



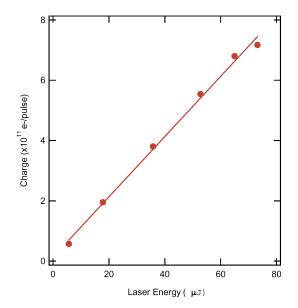
Polarization and QE as a function of wavelength measured in the CTS lab.



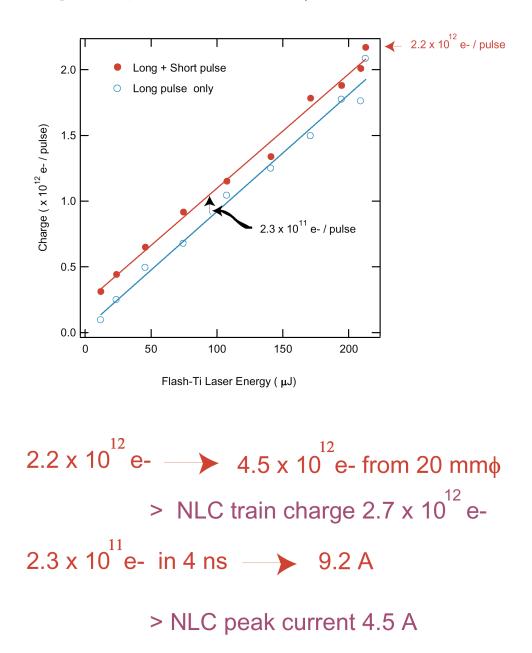


Faraday cup signal measured using varying Flash-Ti laser energies.

Charge output as a function of Flash-Ti laser energy.



#### Charge Output from 14 mm $\phi$ Laser Beam



# Electron sources: R&D items

Polarized rf electron gun :Issues

- Slow response time of GaAs
- Vacuum requirements
- Cathode Sensitivity to dark current
- Cathode Sensitivity to ion bombardment
- Cathode sensitivity to magnetic field

#### S-Band PWT Photoinjector

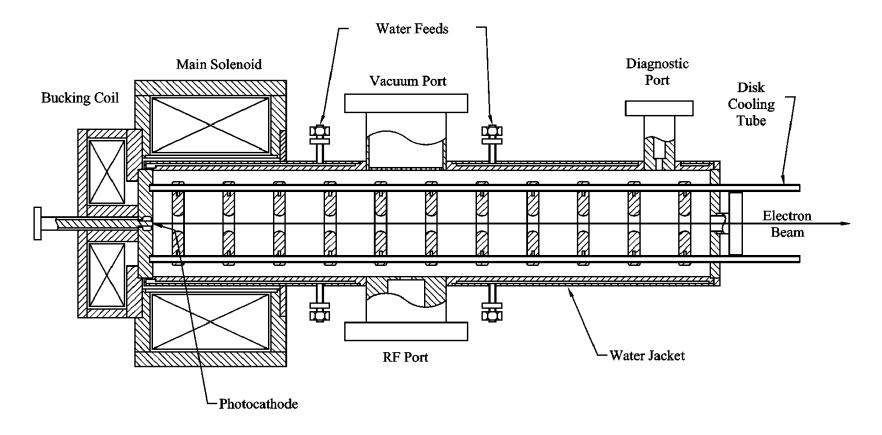


Figure 1: Schematic of the DULY S-Band Integrated PWT Photoelectron Linac.

# -from LC'02 presentation of J.Clendenin (SLAC)

### Electron sources: R&D items: Flat beam electron gun:

- An idea of Brinkmann, Derbenev, and Flottmann
- Impose a solenoidal field at the cathode of an rf photocathode gun
- After emerging from the solenoid, the beam has angular momentum
- The angular momentum may be transformed into an emittance asymmetry (flat beam) with a quadrupole channel matched to the solenoid.
- Experiments at the A0 photoinjector at Fermilab have observed a 50:1 transverse emittance ratio in a 17 MeV electron beam

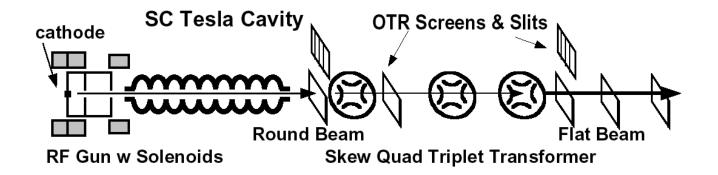


Figure 1: Very schematic rendition of the layout at Fermilab related to this experiment.

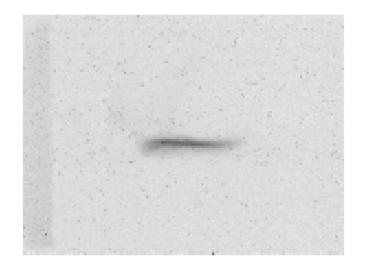


Figure 2: Beam profile on OTR screen 1.2 m downstream of the third skew quadrupole.

### Electron sources: R&D items: Flat beam electron gun

- The actual "flat" emittance in the Fermilab experiment was close to 1  $\mu$ m, still much larger than a damping ring emittance; but emittance compensation was not correct for the optics used.
- The beam is unpolarized. The technique has not yet been applied to polarized-source photocathodes.

### Electron sources: R&D items

Laser system development-slides from NLC review (SLAC)

# Source Laser R+D (Post CDR)

- Use diode laser for source seed
  - Greatly reduced complexity
  - Limited tuning range, electrical bandwidth
- Direct diode pumped lasers: eliminate flash lamps
  - Cr:LiSAF laser crystal: Directly produces the required wavelength
- Diode pumped pump lasers: Eliminate flashlamps
  - Less technically challenging than direct diode pumping final laser
  - Use Nd:YLF (or similar) conventional diode pumped materials
  - Use Yb:YAG newer material higher efficiency
- Increased optics automation reduce the need for expert "tweaking" of laser systems
- If new technologies do not perform as required
  - Study performance of conventional systems
  - construct conventional prototype

# Positron Sources: Potential R&D Items

- Development of undulator-based (polarized) positron source
- Development of laser-based (polarized) positron source
- Positron yield enhancements using crystal targets

## Positron sources: R&D items

Development of undulator-based (polarized) positron source-slides from R. Pitthan, J. Sheppard (LC'02)



### An Immodest Proposal

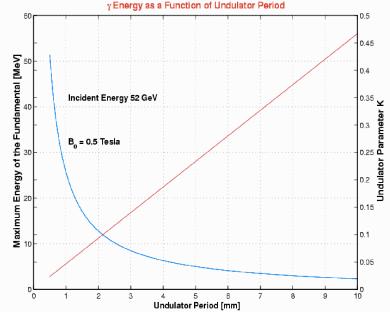
Use the SLAC 50 GeV, low emittance beam in conjunction with a  $\approx$  1-2 mm period helical undulator to demonstrate undulator based production of polarized positrons for linear colliders

Measure the yield, spectrum, and polarization of both the photons and positrons

Do this in the next 18-30 months in the FFTB enclosure:

- Proof of Principle Demonstration
- Validate Codes
- $\bullet \textbf{Develop} \ \gamma \ \textbf{Spin Diagnostics}$
- Develop e+ Spin Diagnostics

•Maybe Get a Surprise (better not)



February 7, 2002

Sheppard/Pitthan

SLAC can produce a single bunch electron beam of  $N_e = 1 \times 10^{10} e^{-/bunch}$ ,  $E_e = 50$  GeV, and  $\gamma \varepsilon_x = \gamma \varepsilon_y = 1.5 \times 10^{-5} m$ -rad For a helical undulator  $\lambda_u = 0.001 m \text{ and } B_0 = 0.5 T$ ,

$$K_{u} = 93.44B_{0}(T)\lambda_{u}(m) = 0.0467$$

$$\Delta E(eV) = 1450 \frac{E_e^2 (GeV) K_u^2}{\lambda_u^2 (cm)} = 7.68 \times 10^5 \ eV / m / e^- = 0.768 \ MeV / m / e^-$$
$$E_{c10} = \hbar \omega_{10} = \hbar \frac{4\pi \gamma^2 c / \lambda_u}{\left(1 + K_u^2\right)} = 23.7 \ MeV$$
$$_{hv} E_{avg} = E_{c10} \times \frac{\sum hsum}{\sum hsum. / ww10} = 0.51 E_{c10} = 12.0 \ MeV / photon$$

$$N_{h\nu} = \frac{\Delta E}{_{h\nu}E_{avg}} = \frac{0.768 \ MeV \ / \ m \ / \ e^{-}}{12.0 \ MeV \ / \ photons} = 0.064 \ photons \ / \ m \ / \ e^{-}$$

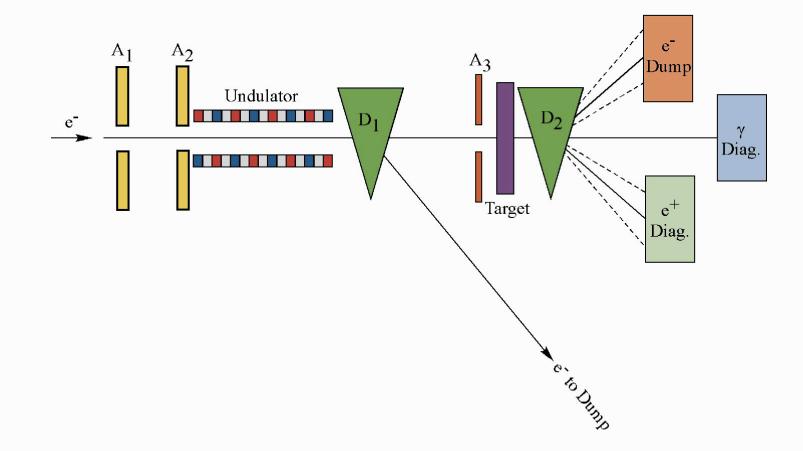
In this energy region,  ${}_{h} = Y_{p}$ , the yield of positrons from gammas incident on 0.4 r.l. of Ti, is about 5%.

For  $N_{-} = 1 \times 10^{10} e^{-}$  per bunch, the expected yield of  $e^{+}$  is then

$$N_{+} = N_{-} \times N_{hv} \times N_{hv} \times N_{p} = 1 \times 10^{10} \times 0.064 \times 0.05 = 3 \times 10^{7} e^{+} / m / bunch$$



#### What Does the Hardware Look Like?



Sheppard/Pitthan

NLC - The Next Linear Collider Project

### **Built and Tested** (Rossmanith)!

- Much R&D exist on short period undulators. Gap:Period typically ≈ 1:4
- Example for planar configuration with a double superconducting solenoid from ANKA (Karlsruhe).
- Period  $\lambda_u$  = 3.8 mm
- Design field B<sub>0</sub> (solenoid center) = 0.5 Tesla, field in gap is 3 times higher

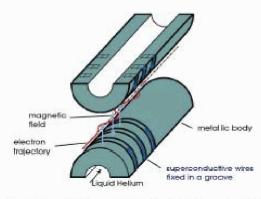
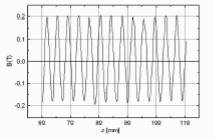


Fig. 1 Layout of the undulator. The field is generated by superconductive wires with alternating current directions. Two identical coils, indirectly cooled by LHe, are placed above and below the electron beam.



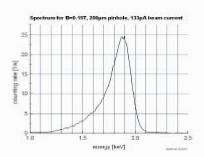


Fig. 3 Field of one undulator coil measured with a miniature Hall probe at a distance of 0.5 mm. The current was 600 A.

- •Experiment done at Mainz at 885 MeV: achieved were 1.8 keV X-rays
- Scaled to 52 GeV @ 0.5 Tesla: 6.2 MeV
- Scaled to 52 GeV @ 1.0 Tesla: 12.4 MeV

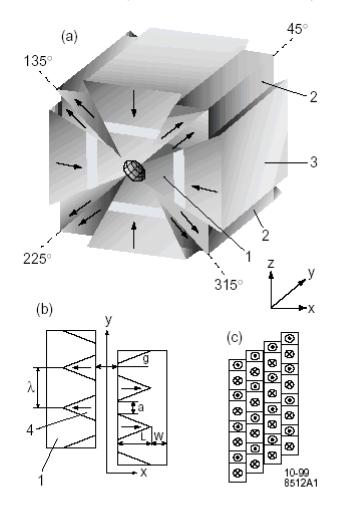
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•Scaled to 52 GeV @ 1.9 mm and 1 Tesla:
≈25 MeV
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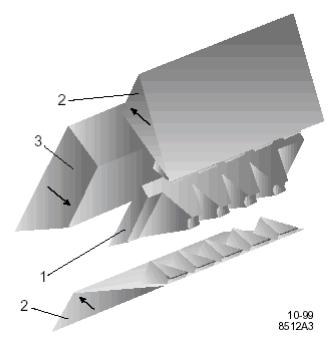


### Designed: Permanent Magnet Helical Design

• At SSRL: hybrid/PM development



SLAC-PUB-8347



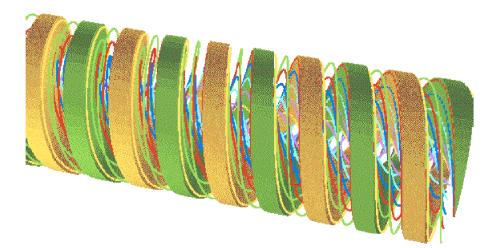
Period structure machined into the steel mono block

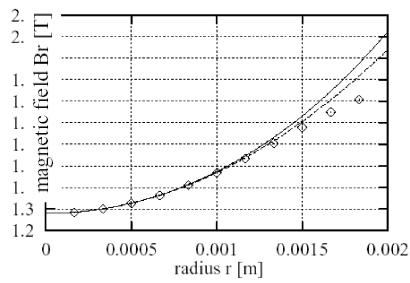
February 7, 2002

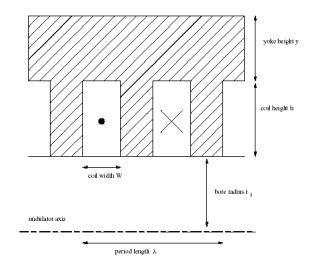
NLC - The Next Linear Collider Project

### **Designed:** Superconduction with Iron

- DESY double helix design (Flöttmann, Wipf)
- Designed for  $\lambda_u = 12 \text{ mm}$ , but can reach smaller values







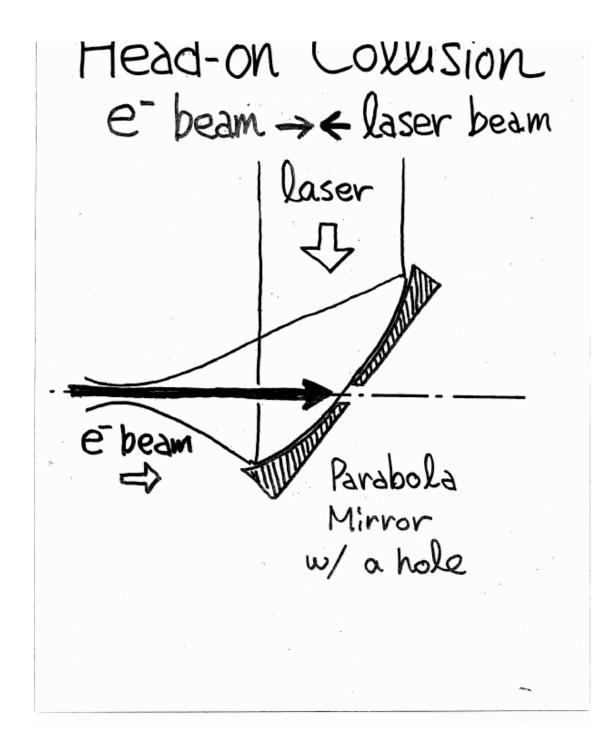
Sheppard/Pitthan

## Positron sources: R&D items

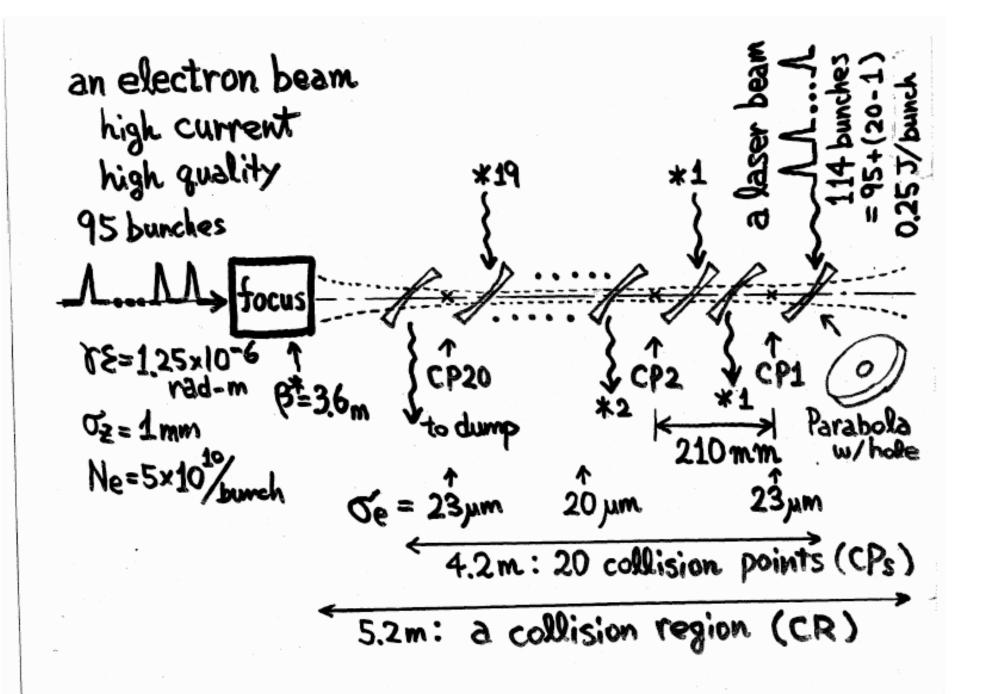
Development of laser-Compton based (polarized) positron source-slides from Tsunehiko Omori (KEK) (LC'02)

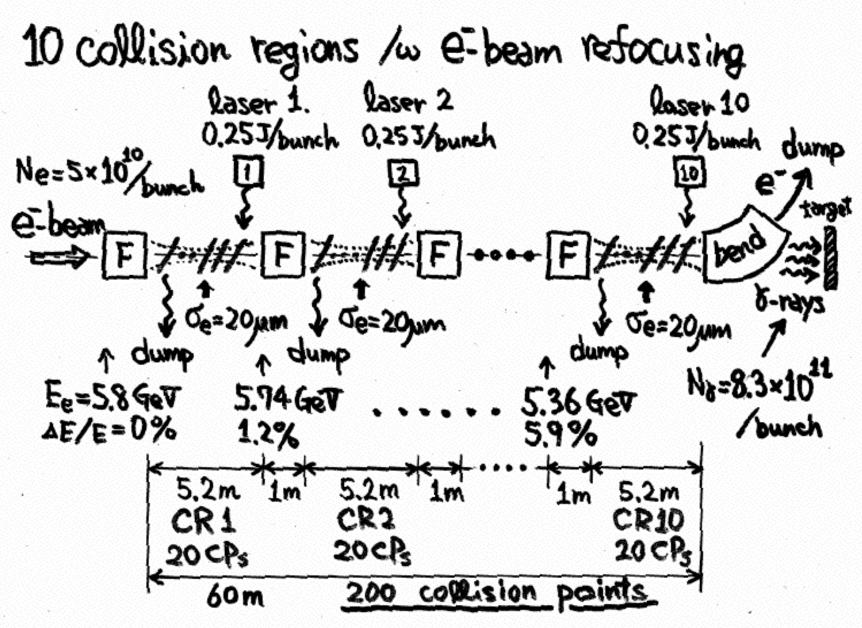
Our Choice Backward Laser-Compton Scattering Circular 2ed CO2 laser (0.117eV, λ=10.6,μm) ebeam Emore = 60 Met 5.8 Get thin target polarized, if we select by energy

Opair (tungsten: W, Z=74) = 25000 mb (3) Since 60 MeV << 5.8 GeV laser



thin Tabler (U.S.XO) lasers Pol. et source 19 3GeV 2.842 D 36**e**₹ BC Linac Linac 1986eD RF Gun beam 5.8Gev **6**-Linac Collision Points N=5×10'%bunch ( Palabola mirrors) 82= 1,25× 10-6 rad-m **ए** = 1। R(スを装) thick target (4-6X.) × 4 ↓ (radiation & heat) onventional et Source 1.98 PreDR 6-10 GeT Thermal 9844 Linac Gun Linac e-beam 6-10 Fev Capture x 4 N=(3-1)x 101%



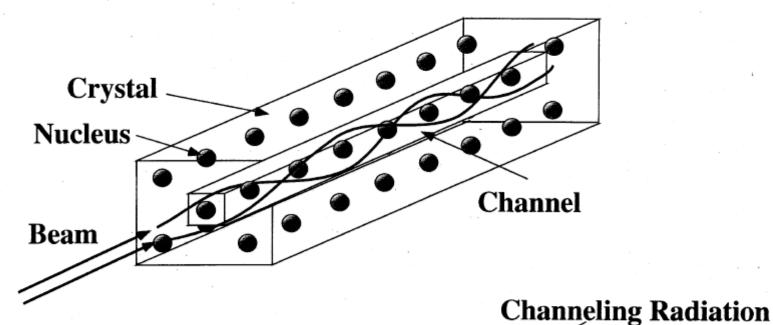


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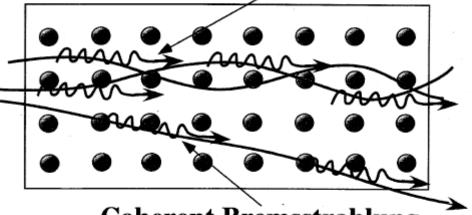
We have pre-conceptual design -CO2 laser ×10 0.25 J/bunch, 114 bunches/train 5.8 GeV high current linac × 1 + Damping Ring  $5 \times 10^{10} e^{-1}$  bunch, 95 bunches Analin 8 E = 1.25 × 10<sup>-6</sup> rad-m (x and #) 200 collision points reuse laser beams refocus an e-beam positrons 1.2 × 10<sup>10</sup> et/bunch (Satty Factor) 95 bunches / train (= 1.1 pol. = 56% Wall Plug Power = 9.4 MW Heat/Thermal problem of target Fleat load ~ 1.5 kW (continuous) Stress 510 MPa (instantaneous) No Problem ?

## Positron sources: R&D items

Positron yield enhancement from crystal targetsslides from Kazura Furukawa (KEK) (LC'02) Channeling and Coherent Bremsstrahlung



 In single crystal these two phenomena enhance e.m. shower (photon) and positron yields



**Coherent Bremsstrahlung** 

K.Furukawa, LC2002, Feb.2002.

Refine

Codes

#### Summary

 Positron Production Enhancement with W Crystal was Measured Dependencies on

Incident Energy (4, 8 GeV),

Target Thickness (2.2, 5.3, 9, etc mm)

Out-going Positron Energy (5,10,15,20 MeV)

- ♦ With Thin (2.2 mm) Crystal 5-Times Enhancement was Observed
- Yield from 9mm Crystal was Larger than 15-28mm Amorphous
- Diamond Compound (Thick Diamond+Tungsten) Target May be promising
- Need Heating Simulation